

ERRATUM

1. Page 15. It is written "...or $m_i^a = m_i^b = \dots = m_i^f = 0$ ". It should be "...or $m_i^a = m_i^b = \dots = m_i^f$ ".
2. Page 23. There is an extra space before the subscript in TaSi₂ in Fig. 5.
3. Page 36. 1, 2, A and layer 3 in Fig. 9 refer to the SEM micrograph in the original paper, and have no meaning here. Therefore, they should be ignored.
4. Appendix I page 64. The annealing ambient should be 10^{-4} Pa.
5. Appendix III page 2939. Jyrki has been misspelled.
6. Appendix III page 2945. Valtion has been misspelled.
7. Appendix IV page 3. It is written "... (about 20-30 μm in diameter)". It should be "... (about 20-30 μm in diagonal).
8. Appendix V page 3. It is written "... films were sputtered onto cleaned..." it should be "... films were sputter-deposited onto cleaned...".